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ABSTRACT.

10 [PROBLEMS] To provide a metal complex compound capable  
of being suitably used for manufacturing a metal-contain-  
ing thin film by the CVD method and a method for prepar-  
ing a metal-containing thin film.

15 [MEANS FOR SOLVING PROBLEMS] A metal complex compound  
comprising a  $\beta$ -diketonato ligand having an alkoxyalkyl-  
methyl group, and a method for preparing a metal-contain-  
ing thin film using the metal complex compound by the CVD  
method.